

First Named Inventor	Ravi Iyer	<p style="text-align: center;">INFORMATION DISCLOSURE STATEMENT</p>
Serial No.	Unknown	
Filing Date	Herewith	
Group Art Unit	Unknown	
Examiner Name	Unknown	
Confirmation No.	Unknown	
Attorney Docket No.	400.083US03	
<p>Title: COMPOUND STRUCTURE FOR REDUCED CONTACT RESISTANCE</p>		

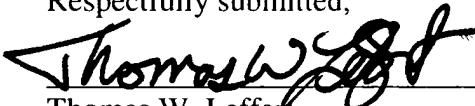
Mail Stop: PATENT APPLICATION
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

In compliance with 37 C.F.R. §§ 1.56 and 1.97, *et seq.*, the enclosed materials are brought to the attention of the Examiner for consideration in connection with the above-identified Application. Applicant respectfully requests that this Information Disclosure Statement be entered and the references listed on the attached Form 1449 be considered by the Examiner and made of record. Pursuant to MPEP §609, Applicant further requests that the Examiner initial next to each reference on the Form 1449 to indicate that the listed references have been considered. Applicant further requests that a copy of the initialed Form 1449 be returned with the next official communication.

Further pursuant to MPEP §609, because all of the references listed on the attached Form 1449 have been previously submitted and made of record in the parent application, U.S. Patent Application 09/858,617, filed May 16, 2001, copies of the references previously made of record in the parent application are not submitted herewith.

If the Examiner has any questions or concerns regarding this application, please contact the undersigned at the number listed below.

Date: 21 Oct 03

Respectfully submitted,


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F – 612/312-2250

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Title: COMPOUND STRUCTURE FOR REDUCED CONTACT RESISTANCE		Sheet 1 of 1

U.S. Patent References				
Examiner Initials	Patent No.	Issue Date	Name	Filing Date
	4,816,424	03/28/1989	Watanabe	11/10/1986
	5,049,975	09/17/1991	Ajika	03/12/1990
	5,633,200	05/27/1997	Hu	05/24/1996
	5,654,235	08/05/1997	Matsumoto	06/22/1995
	5,847,463	12/08/1998	Trivedi	08/22/1997
	6,002,174	12/14/1999	Akram	12/31/1997
	6,080,665	06/27/2000	Chen	04/11/1997
	6,081,034	06/27/2000	Sandhu	01/23/1998
	6,093,615	07/25/2000	Schuele	08/15/1994
	6,100,185	08/08/2000	Hu	08/14/1998
	6,121,134	09/19/2000	Burton	04/21/1998
	6,147,405	11/14/2000	Hu	02/19/1998
	6,475,907	11/05/2002	Taguwa	04/18/2000

Foreign Patent References					
Examiner Initials	Foreign Patent		Name	Publication Date	T?
	Country	No.			

Other References	
Examiner Initials	Author, Title, Date, Pages, etc.

Examiner Signature		Date Considered	
*Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.			